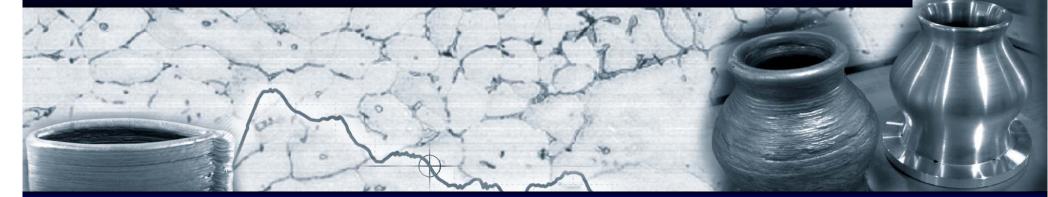


Electron Beam Additive Manufacturing: State-of-the-Technology, Challenges & Opportunities

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www.nasa.gov





Direct Digital Manufacturing Workshop

Solomons, MD

May 11-12, 2010

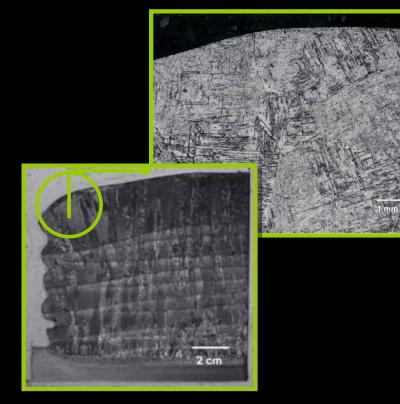
Electron Beam Freeform Fabrication (a.k.a.: EBF³, EBFFF, EBAM)



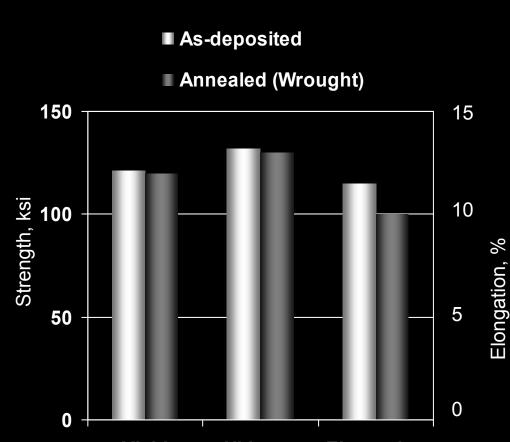
- Electron beam deposition with wire feed
- High deposition rates, large part sizes
- Near-net shape with finished machining

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Ti-6AI-4V Processed by EBF³



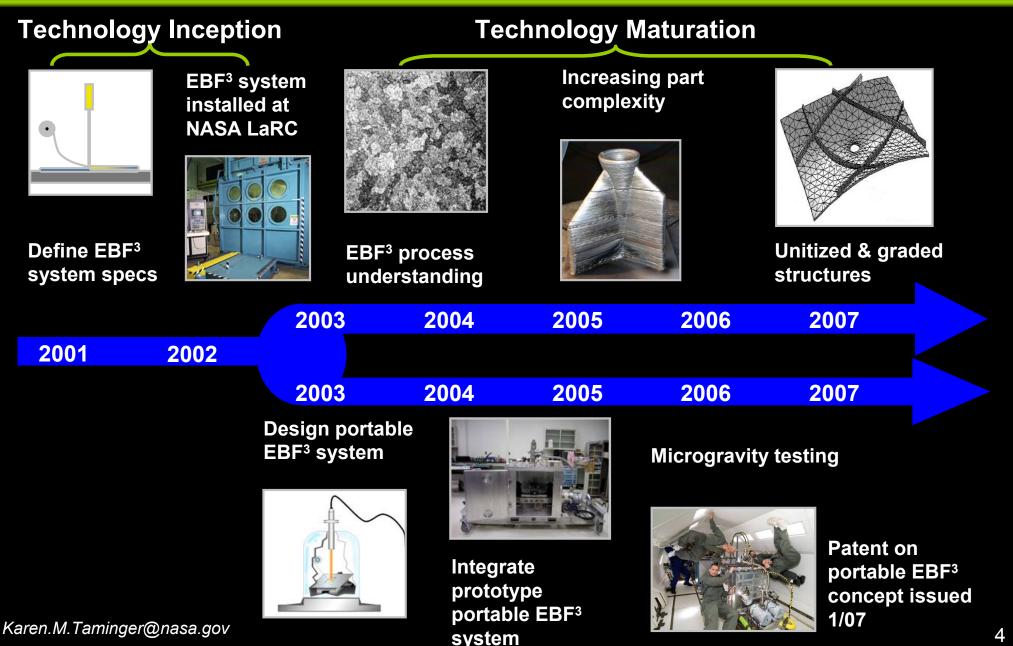
- Large columnar grains grow epitaxially from substrate
- Forms typical alpha-beta lath structure within grains



Yield Ultimate Elongation

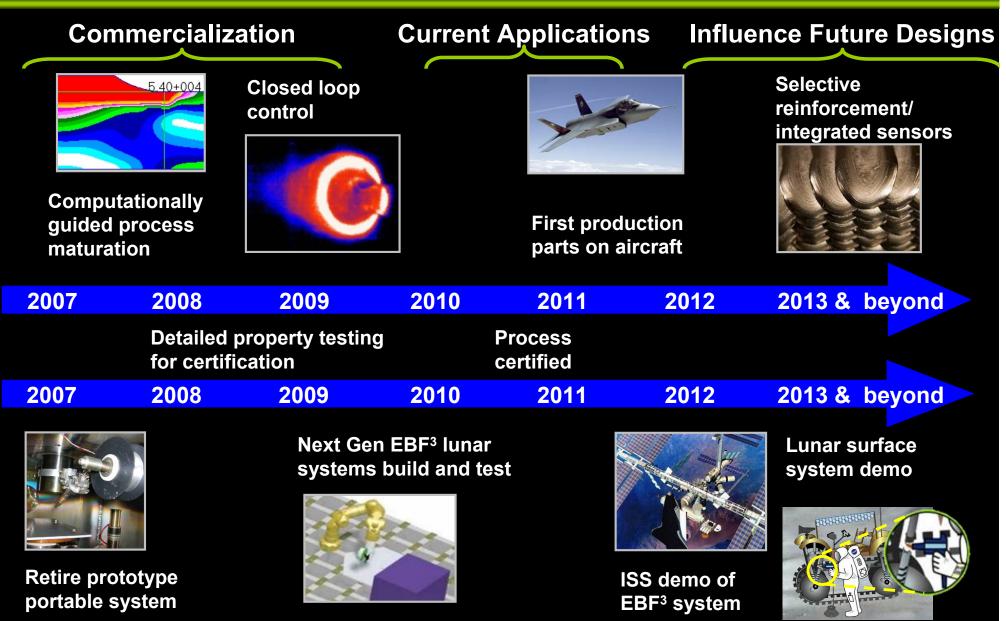
Properties of EBF³ deposited Ti-6-4 equivalent to annealed wrought product

History of EBF³ Development

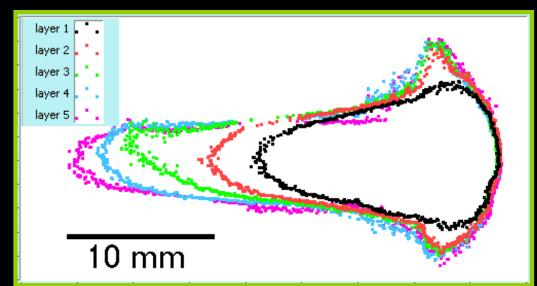


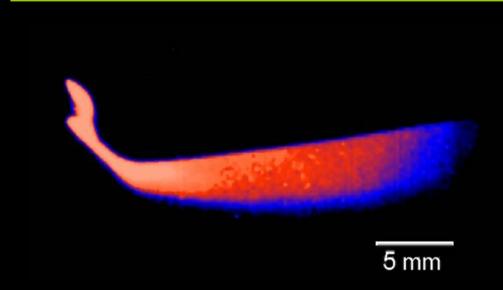
Future of EBF³





Need for Process Control





Problem:

Melt pool changes with temperature from one layer to the next

Current Solution:

Monitor melt pool size as indication of temperature for process control

Required Work:

•Complete integration of sensors into control system

•Refine control logic to correct for other process anomalies (wire irregularities, change in direction)

Loss of Al in Ti-6Al-4V

Problem:

Al loss in Ti-6-4 due to melting in vacuum (function of temperature & pressure)

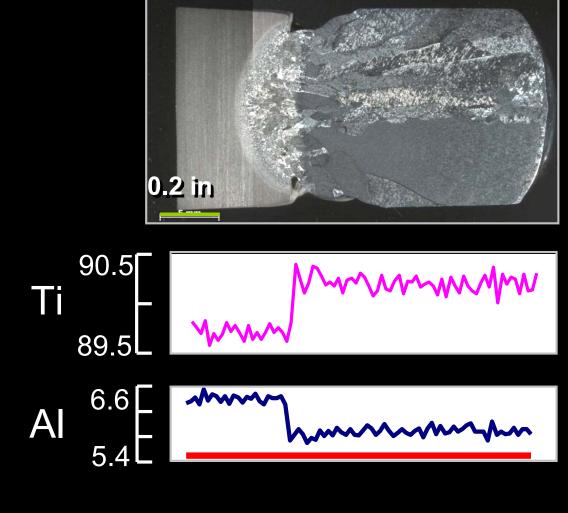
Current Solution:

↑ Al in wire composition↓ thermal input

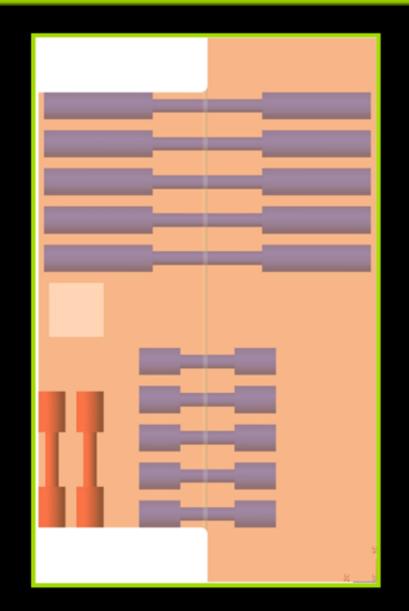
Required Work:

•Quantify losses at standard operating parameters to ensure consistency

•Process development to reduce Al loss by reducing thermal input



Certification & Repeatability



Problem:

Part-to-part and machine-to-machine variations limit repeatability

Current Solution:

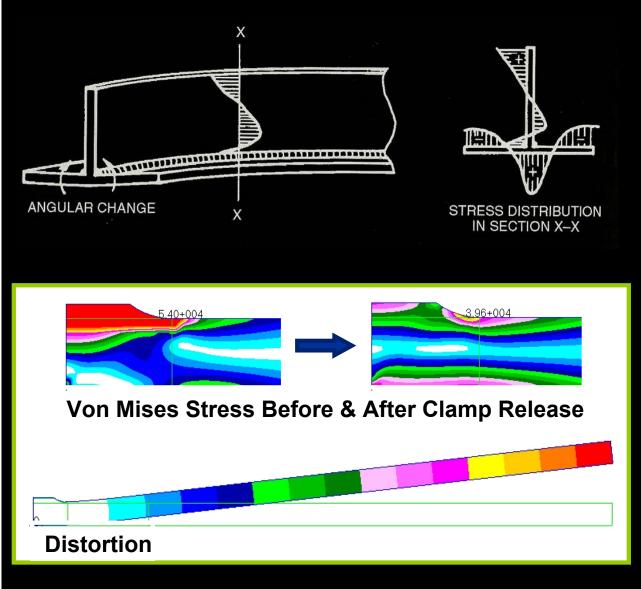
Define tight process specification & conduct allowables testing

Required Work:

- •Compare parts built on different machined with similar build parameters
- •Beam probe analysis to monitor beam degradation with filament life

•Generate & maintain database with pedigree data from multiple deposition sites

Distortion and Residual Stress



Problem:

Temperature gradients induce residual stresses & distortion

Current Solution:

- Balanced deposition on both sides of baseplate
- •Frequent thermal stress relief steps

Required Work:

Post-deposition stress relief

 Modeling & validation of distortion & residual stress

 Process development to reduce distortion in one-sided deposits

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NDE Analysis of EBF³ Parts

Problem:

Irregular surface finish of as-deposited EBF³ parts obscures NDE results

Current Solution:

NDE inspection after final machining

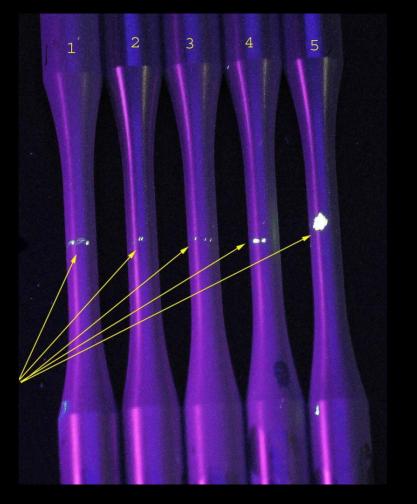
Required Work:

•NDE technique development to detect internal flaws without machining

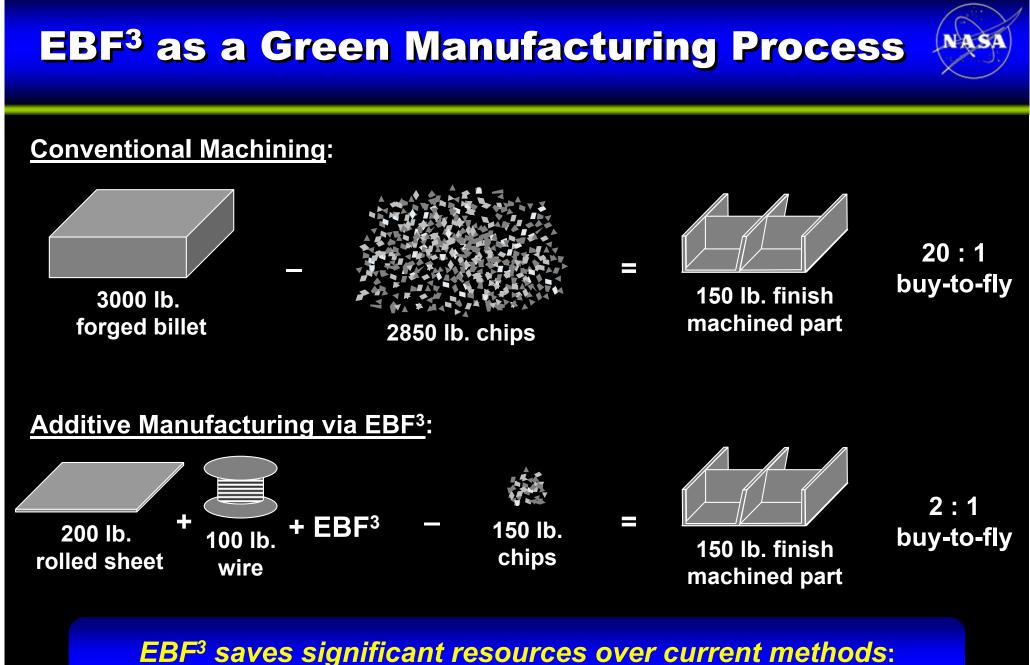
•Process development to eliminate flaws

•Sensors incorporated into process control system to enable real-time NDE during deposition

Lack of fusion at substrate/ deposit interface







raw materials, energy, fewer chemicals (cutting fluids), lead time = cost

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Repair via EBF³



Opportunity:

Repair capability for large damaged parts that are irreparable by current technologies

- High value components (new or damaged in service)
- Reduce lead time to repair

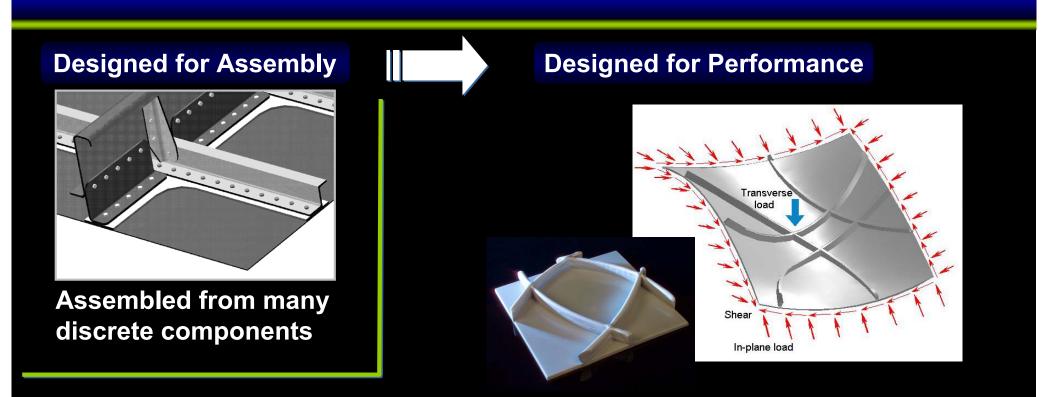
Required Work:

- •Tolerance control (residual stress, distortion)
- •Material condition (HAZ, heat treat)
- •Repair design (programming, stress analysis)
- Qualification (MRB)

* LM Aero ADP currently has three such parts and seeks funding to develop the



Novel Structural Designs



• Freeform fabrication of unitized structure allows use of functionally graded, locally controlled features

- New structural design & analysis tools allow concept development of structures with contoured stiffeners that follow load paths
- New manufacturing process coupled with novel structural analysis and design enables performance enhancements and reduced cost, weight

EBF³ Far Term Possibilities

- Complex geometries not possible with conventional processes
- Integrated multi-functional components
- Functional gradient materials
- Selectively reinforced metals
- Controlled microstructures
- Integrated sensors

